

Amendment to the Drawings:

The attached sheets of drawings include changes to FIGs. 2B-2H. These sheets, which include FIGs. 2A-2H, replace the original sheets including FIGs. 2A-2H. In the amended FIGs. 2B-2H, first opening 213 and contact plug 216 are formed in the second dielectric layer 211 and the first dielectric layer 209, and are connected to polysilicon word lines 207.

Attachment: Replacement Sheets

Annotated Sheets Showing Changes

REMARKS

Claims 8-15, 17-18 and 24-29 have been allowed. At this time, the specification and the drawings are amended to correct some obvious errors in the specification and drawings. As is well known to those ordinary skill in the art, the first opening 213 and the contact plug 216 as illustrated in the specification and FIGs. 2B-2H should be formed in dielectric layer(s) to be connected to a conductive layer such as the silicon word lines 207, thereby the conductive layer can be electrically connected to the outside via the contact plug 216.

The amendments of the claimed patent application made by Applicants after the mailing of the Notice of Allowance are complied with 37 CFR 1.312. Applicant submits that no new matter has been added, and the entry of the amendments of the specification and drawings are respectfully requested.

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Respectfully submitted,

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Annotated Sheet Showing Changes

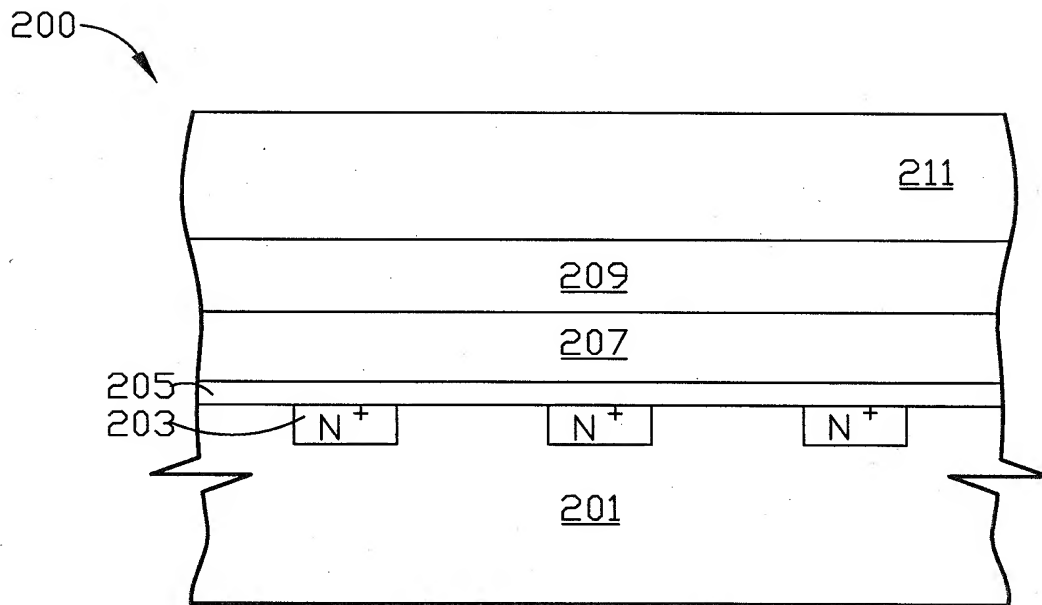


FIG.2A

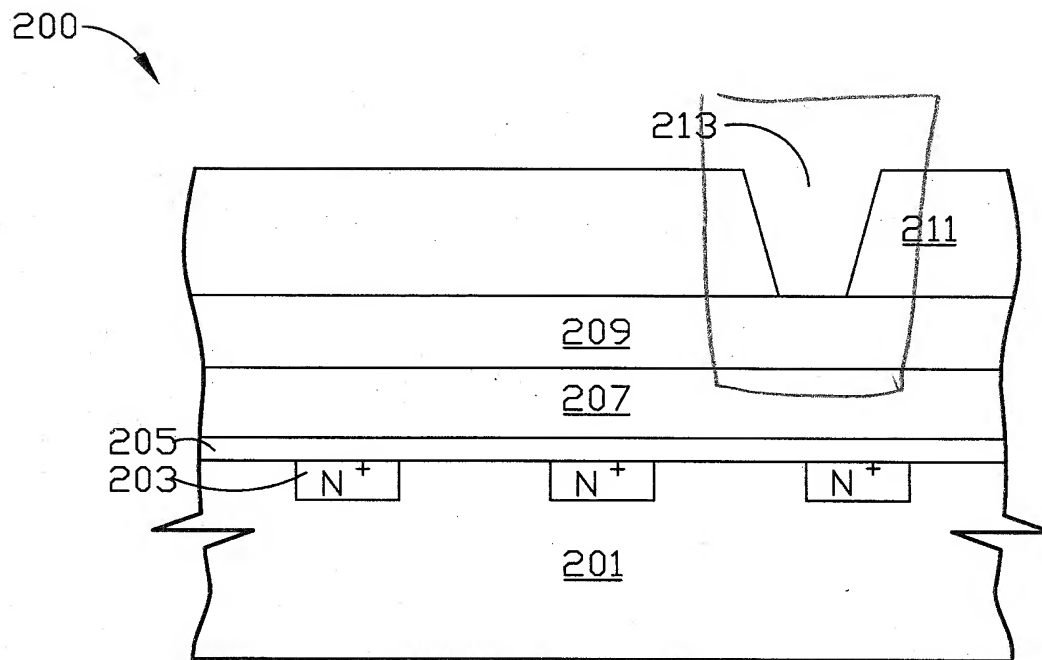


FIG.2B

Annotated Sheet Showing Changes

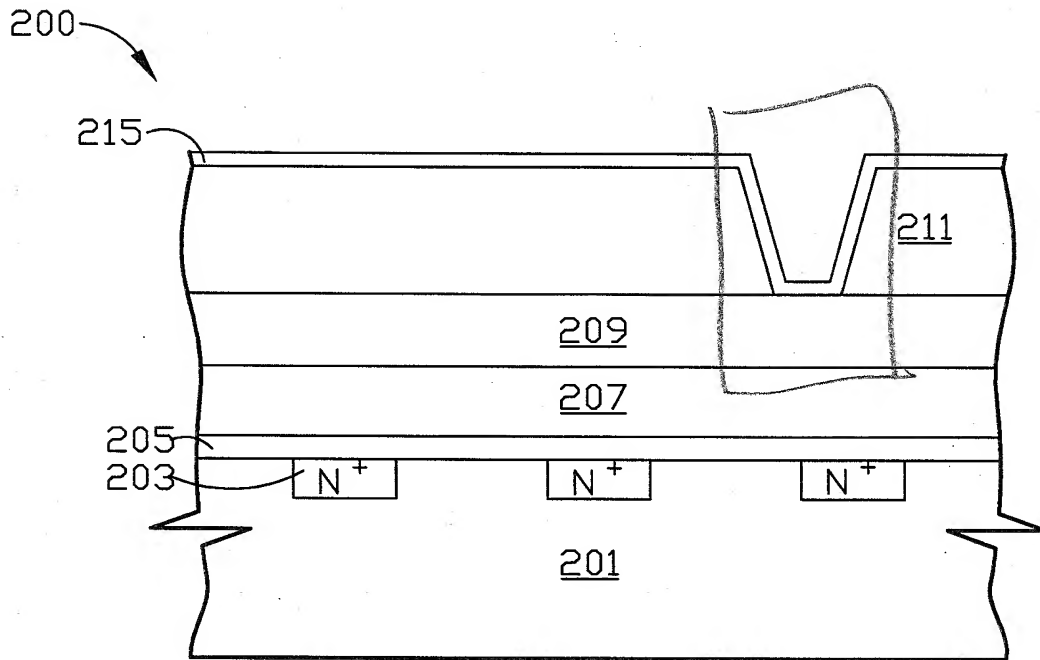


FIG. 2C

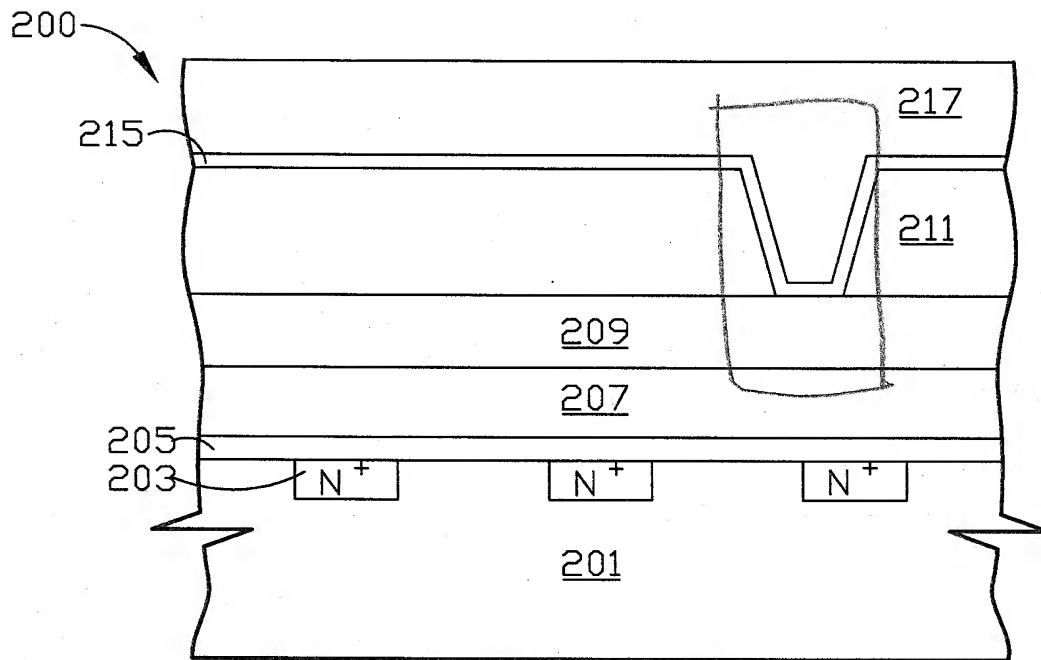


FIG. 2D

Annotated Sheet Showing Changes

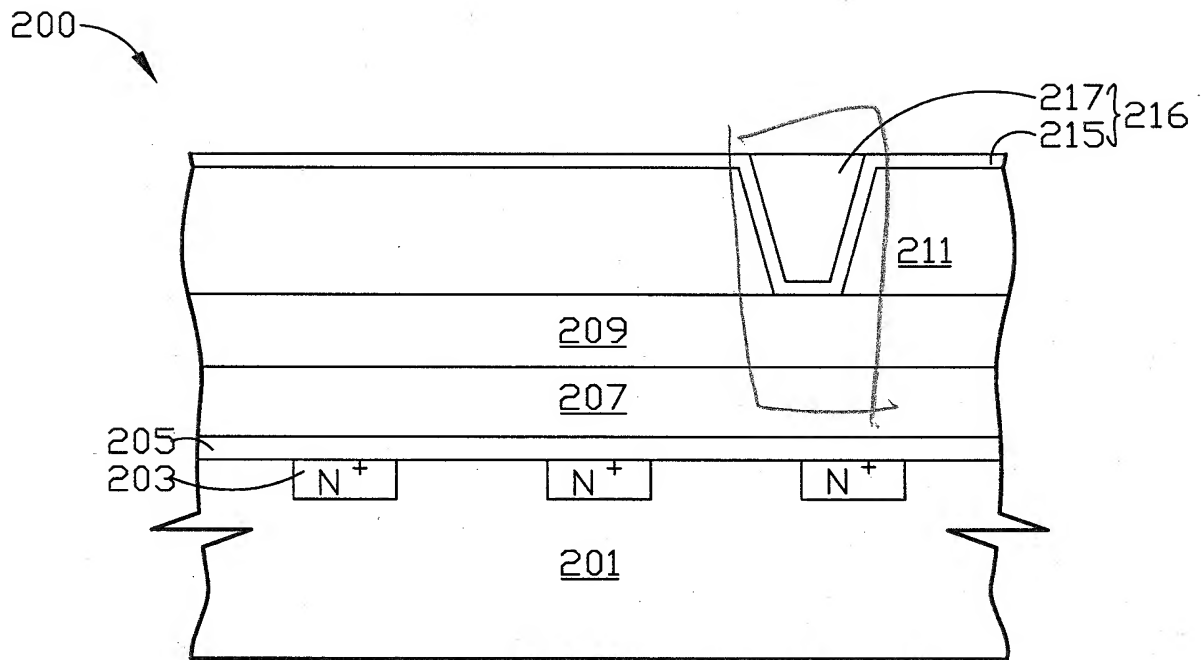


FIG. 2E

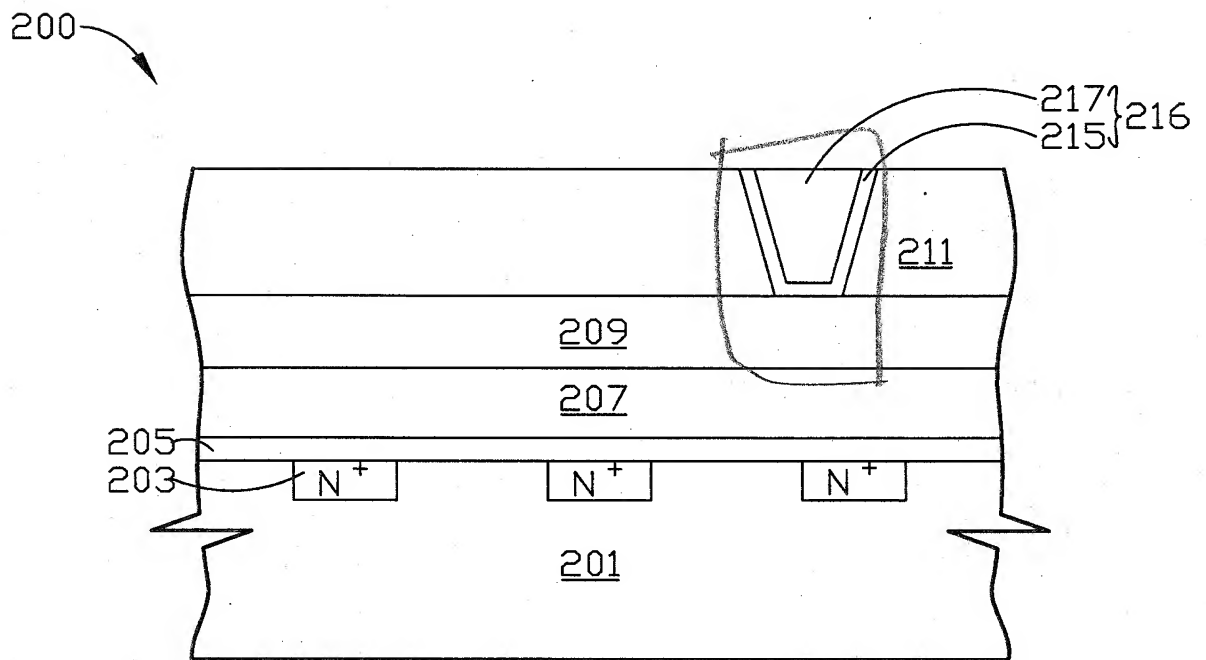


FIG. 2F

Annotated Sheet Showing Changes

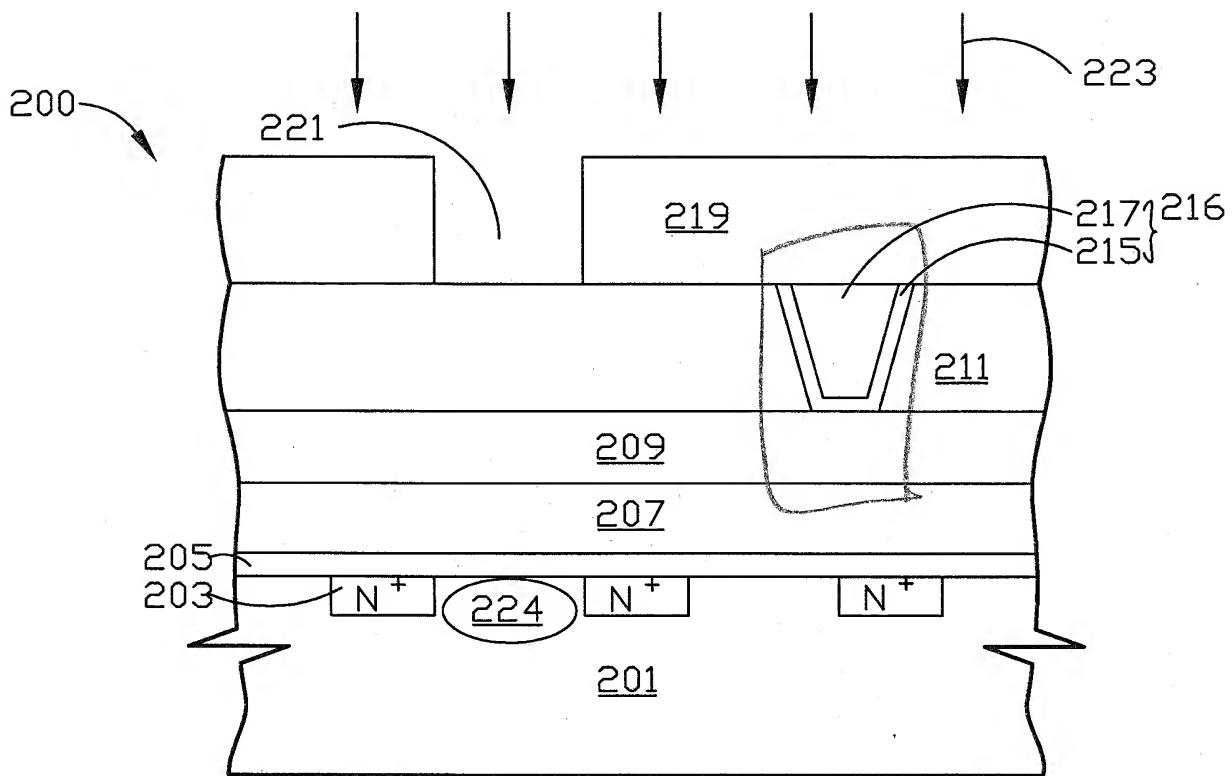


FIG. 2G

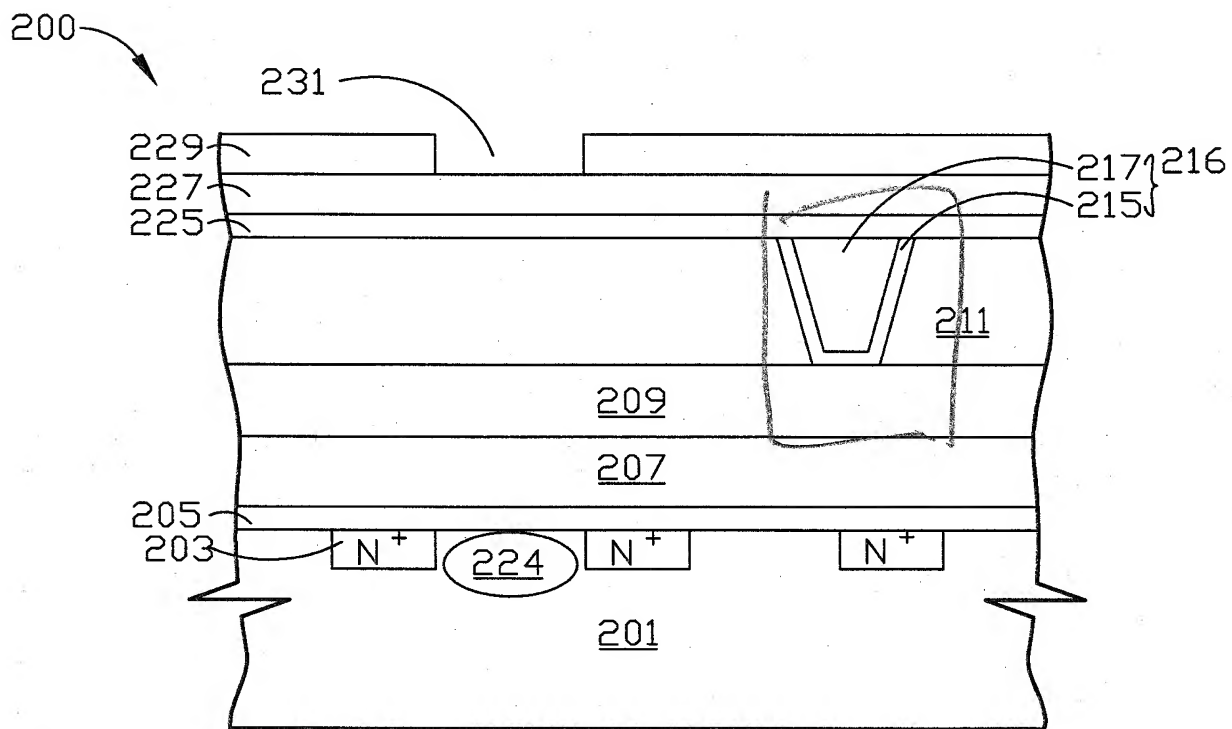


FIG. 2H